www.rsc.org/chemcomm

ChemComm

The trimethylsilylation of acetylene

B. Chiavarino, M. E. Crestoni* and S. Fornarini

Dipartimento di Studi di Chimica e Tecnologia delle Sostanze Biologicamente Attive, Università di Roma "La Sapienza", P.le A. Moro 5, I-00185 Roma, Italy. E-mail: mariaelisa.crestoni@uniroma1.it

Received (in Cambridge, UK) 11th April 2002, Accepted 15th May 2002 First published as an Advance Article on the web 31st May 2002

The gas-phase reaction of Me_3Si^+ ions with acetylene is remarkably sensitive to the environment, leading to substitution products in radiolytic systems at atmospheric pressure and to rearranged adduct ions in the FT-ICR cell at 10^{-8} Torr, while seeming unproductive in an intermediate pressure range.

The ion molecule reactions of Me₃Si⁺ ions, easily accessible species in the gas phase, provide an entry into the rich chemistry of organosilicon cations, a subject of significant current interest.¹ This interest is based in part on the fact that a silyl substituent may exert conspicuous effects on the stability of carbocations as shown by several α - and β -silyl-substituted carbocations. For example, incipient α -silyl-substituted carbenium ions, Me₃SiCHCH₃⁺, generated in the gas phase from different precursors, give a mixture of isomeric ions by 1,2-H and 1,2-Me migrations, as clarified by mass spectrometric and computational studies.^{2–4} Conversely, stable silyl-substituted vinyl cations have been observed in the gas phase, where α silylvinyl cations, Me₃SiC=CH₂⁺, could be produced by MS and identified as distinct species.⁵

Recently, silyl-substituted unsaturated carbocations have been even invoked as intermediates in the formation of neutral silylated products arising from the reaction of radiolytically formed Me₃Si⁺ with alkynes in a gaseous medium at atmospheric pressure.⁶ In the exemplary reaction of Me₃Si⁺ with acetylene the deprotonation of Me₃Si⁺–acetylene adduct, described either as the open species (**A**) or as the bridged structure (**B**), produced high yields of Me₃SiC=CH.

$$\begin{array}{ccc} Me_{3}Si & Me_{3}Si \\ HC=CH^{+} & HC \overset{+}{=} CH \\ \hline \textbf{(A)} & \textbf{(B)} \end{array}$$

This result stands in contrast with the report of a highpressure mass spectrometric (HPMS) study of the same reaction which failed to produce any detectable abundance of the Me₃Si⁺-acetylene adduct.⁷ The reason for this failure was ascribed to the unfavourable thermodynamics for the binding of Me₃Si⁺ with acetylene relative to water. Traces of adventitious water made this ligand a too effective competitor. However, in the same high-pressure ion source the equilibria for the association of Me₃Si⁺ with alkenes⁸ and higher alkynes⁷ were fully characterized. In particular, the thermodynamic parameters for the association with ethylene were determined, namely a ΔH° value of -23.6 kcal mol⁻¹ and a ΔS° value of -38.5 cal K^{-1} mol⁻¹. These data are consistent with the high yield of Me₃SiCH=CH₂ formed by the radiolytic reaction of Me₃Si⁺ with C₂H₄ at the partial pressure of 5 Torr.⁶ At the same time they predict the equilibrium to lie on the reactant side at ca. 5 \times 10^{-8} Torr C₂H₄, the operative pressure in Fourier transform ion cyclotron resonance (FT-ICR) mass spectrometry. Accordingly Me_3Si^+ appears unreactive with C_2H_4 by FT-ICR. Along this line of reasoning it was quite unexpected to find that Me₃Si⁺ does indeed react with $C_2 \dot{H}_2$ and higher homologues in FT-ICR, yielding a formal adduct ion.9 Collision induced dissociation (CID) and ion-molecule reactions have been used to probe the structure of the C₅H₁₁Si⁺ ions at *m/z* 99 that are formed by the Me₃Si⁺ reaction with C₂H₂ in the FT-ICR cell at 4×10^{-8} Torr [eqn. (1)]. The bimolecular rate constant *k* equal to $1.3 (\pm 0.3) \times 10^{-11}$ cm³ molecule⁻¹ s⁻¹ shows that the reaction is relatively inefficient (eff = k/k_{coll} = 0.013), leading exclusively to C₅H₁₁Si⁺ ions (1).

$$Me_{3}Si^{+} + HC \equiv CH \rightarrow C_{5}H_{11}Si^{+}$$
(1)

'On resonance' CID of **1** shows the fragmentations to $SiC_2H_7^+$ + C_3H_4 (60%) and to $SiC_3H_9^+$ + C_2H_2 (40%) as dominant channels. Even if CID results do not offer a conclusive evidence of ion structure, the detection of $SiC_2H_7^+$ indicates the formation of a covalent Si–C bond within **1**.

The presence of an intact acetylene ligand can be excluded on the basis of the bimolecular reactivity of **1** towards stronger Lewis bases, such as propyne and acetone. In fact these compounds are found unable to displace acetylene to give the corresponding trimethylsilylated adduct.

Also water is unable to give a silylated adduct, rather, it reacts relatively rapidly ($k = 2.2 (\pm 0.5) \times 10^{-10} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$) and specifically by the exclusive elimination of C₃H₆ and concomitant formation of Me₂SiOH⁺ at m/z 75 [eqn. (2)].

$$\mathbf{1} + \mathbf{H}_2 \mathbf{O} \rightarrow \mathbf{M} \mathbf{e}_2 \mathbf{S} \mathbf{i} \mathbf{O} \mathbf{H}^+ + \mathbf{C}_3 \mathbf{H}_6 \tag{2}$$

It may be mentioned that when the Me₃Si⁺–acetone adduct, containing an intact trimethylsilyl group, is allowed to react with water no detectable formation of any m/z 75 product was observed.

All these findings point to a nascent Me₃Si⁺-acetylene species that has entirely rearranged into a more stable silylenium ion, [Me₂SiC₃H₅]⁺, by methyl transfer from Si to C with ensuing charge localization on silicon. In the H₃Si⁺acetylene model reaction, ab initio calculations have shown that the H₃Si⁺-acetylene adduct may undergo a two-step isomerization to the more stable 1-silaallyl cation.¹⁰ This rearrangement requires passing beyond a significant barrier. The top of the barrier, however, lies below the energy level of the H₃Si⁺⁻ acetylene couple. On the assumption that a similar potential energy diagram holds also for the Me₃Si⁺-acetylene system under study, the same isomerization process to 1-silaallyl cation should take place. In fact, the interaction energy released in the formation of the Me₃Si⁺-acetylene adduct, and stored as internal energy of the complex, allows the primary adduct (A or B) to overcome the barrier for the isomerization to a Si-centered cation. This is obviously due to the absence of efficient collisional deactivation at the low pressure of the FT-ICR cell.

To gain further insight into the isomerization process leading to **1**, model ions were sought by protonation or dissociative ionization of suitable precursors.

The protonation of trimethylsilylacetylene, Me₃Si–C=CH, by any of a variety of cationic Brønsted acids, AH⁺, produces a mixture of ions whose relative abundances depend on the gas phase basicity of A. An ion corresponding to the protonated species at m/z 99, C₅H₁₁Si⁺ is detected, in noticeable amounts when A is C₃H₆ or *i*-C₄H₈. This ion exhibits CID mass spectra and bimolecular behavior with water and propyne identical to that of **1**. These FT-ICR results testify that the silyl-substituted

1418

vinyl cation $Me_3SiC_2H_2^+$, which is generated by protonation, may store enough internal energy to dissociate to reagents and/ or to undergo isomerization.

Isomeric ions such as Me₂SiC(CH₃)=CH₂⁺ (**2**) and Me₂SiCH=CH(CH₃)⁺ (**3**), formed by 25 eV electron bombardment of Me₃SiC(CH₃)=CH₂ and *trans*-Me₃SiCH=CH(CH₃), respectively, have also been investigated. The reaction of each species with water gave product ions at m/z 75 by loss of C₃H₆ at the same rate shown by **1**, namely $k = 2.0 ~(\pm 0.5) \times 10^{-10}$ cm³ molecule s⁻¹.

Whereas the formation of **2** from the Me₃Si⁺–acetylene adduct should involve a 1,2-hydrogen migration preceding a 1,2-methyl transfer, the formation of **3** might result from **2** by a reversible β -hydrogen migration/alkyne insertion process, in analogy to the reaction pathway connecting Me₂Si(*i*-C₃H₇)⁺ and Me₂Si(*n*-C₃H₇)⁺.⁴ A further possible route, the rearrangement of Me₃Si⁺–acetylene to Me₂SiCH=CH(CH₃)⁺ by 1,3-methyl transfer is highly unlikely because it should involve a high kinetic barrier.²

In conclusion, the reaction of Me₃Si⁺ with acetylene provides a neat example of the role of the environment, notably the operative pressures, on the course of ion-molecule reactions in the gas phase. In the radiolytic approach, the presence of a neutral (M) at 5-50 Torr favors the formation of adduct ions, such as Me₃Si⁺–M, that rapidly reach thermal equilibration with the environment due to frequent unreactive collisions with a bulk gas at the typical pressure of 1 atm. Any excess energy released in the formation of the adduct from the separated reactants may thus be dissipated before any rearrangement or fragmentation process is allowed to occur. This behavior is shown in the reaction of Me₃Si⁺ with both C_2H_2 and C_2H_4 leading to adduct ions that survive long enough to be deprotonated by an added base and yield the corresponding substitution products.⁶ At the other extreme, the 10⁻⁸ Torr pressure of M, that is typical of FT-ICR conditions, prevents any efficient collisional cooling, and adduct ions retain the energy to undergo back dissociation. The Me₃Si⁺ reaction with acetylene succeeds in leading to long-lived adducts shown to have the structure of rearranged Me₂Si-C₃H₅⁺ ions. The access to these more stable isomers is permitted by an energy barrier that lies below the energy level of the reactant pair. Conversely, the barrier for the isomerization of Me₃Si⁺-ethylene is computed to rise above the energy of the Me₃Si⁺ + C₂H₄ couple² and therefore Me₃Si⁺ behaves as unreactive with ethylene in FT-ICR. At the intermediate pressures of HPMS or of flowing afterglow techniques, adduct ions such as Me₃Si⁺-ethylene may be collisionally stabilized^{8,11} but, within this range, in certain cases the relative pressures may be such as to obscure the formation of possible significant products.⁸



Notes and references

- (a) N. Goldberg and H. Schwarz, in *The Chemistry of Organic Silicon* Compounds, eds. Z. Rappoport and Y. Apeloig, Wiley, Chichester, 1998, ch. 18, p. 1105; (b) S. Fornarini, in *The Chemistry of Organic* Silicon Compounds, eds. Z. Rappoport and Y. Apeloig, Wiley, Chichester, 2001, ch. 18, p. 1027; (c) H. U. Siehl and T. Müller, in *The* Chemistry of Organosilicon Compounds. eds. Z. Rappoport and Y. Apeloig, Wiley, Chichester, 1998, ch. 12, p. 595.
- 2 Y. Apeloig, M. Karni, A. Stanger, H. Schwarz, T. Drewello and G. Czekay, *Chem. Commun.*, 1987, 989.
- 3 T. Drewello, P. C. Burgers, W. Zummack, Y. Apeloig and H. Schwarz, Organometallics, 1990, 9, 1161.
- 4 R. Bakhtiar, C. M. Holznagel and D. B. Jacobson, J. Am. Chem. Soc., 1992, **114**, 3227.
- 5 G. A. McGibbon, M. A. Brook and J. K. Terlouw, *Chem. Commun.*, 1992, 360.
- 6 B. Chiavarino, M. E. Crestoni and S. Fornarini, J. Am. Chem. Soc., 1998, 120, 1523.
- 7 W. Zhang, J. A. Stone, M. A. Brook and G. A. McGibbon, J. Am. Chem. Soc., 1996, **118**, 5764.
- 8 X. Li and J. A. Stone, J. Am. Chem. Soc., 1989, 111, 5586.
- 9 In the FT-ICR experiments, performed on a Bruker Spectrospin Apex TM 47e mass spectrometer equipped with a 4.7 T superconducting magnet, Me₃Si⁺ cations were generated by ionization of CH₄–SiMe₄ (99.5:0.5) mixtures in the external chemical ionization source at ~4 × 10⁻⁵ Torr (1 Torr = 133 Pa) and transferred into the 'infinity' cell containing a known pressure, typically in the range of 1–5 × 10⁻⁸ Torr, of the neutral reagent.
- 10 A. E. Ketvirtis, D. K. Bohme and A. C. Hopkinson, J. Phys. Chem., 1994, 98, 13225.
- 11 D. Hajdasz and R. Squires, Chem. Commun., 1988, 1212.
- 12 The only ionic product that is observed is due to addition of Me_3Si^+ to traces of background H_2O .